

Notice of References Cited	Application/Control No. 10/783,034		Applicant(s)/Patent Under Reexamination PELLENS, RUDY JAN MARIA	
	Examiner Kevin Quinto		Art Unit 2826	Page 1 of 1

U.S. PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
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NON-PATENT DOCUMENTS

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
	U	Malik et al., "Polymer Structural Variation Towards Enhancing KrF Resist Lithographic Properties," Journal of Photopolymer Science and Technology, 1998, Vol. 11, No. 3, p. 431-438
	V	
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